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APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/940,788 08/29/2001		Yuji Ono	011075	4613	
23850 7:	590 11/20/2002				
ARMSTRONG,WESTERMAN & HATTORI, LLP 1725 K STREET, NW. SUITE 1000			EXAMINER		
			PERRIN, JOSEPH L		
WASHINGTON, DC 20006			ART UNIT	PAPER NUMBER	
			ARTONII	PAPER NUMBER	
			1746	l L	
	·		DATE MAILED: 11/20/2002	7	

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application N	o	Applicant(s)	_			
Office Action Summary		09/940,788		ONO ET AL.				
		Examiner		Art Unit				
		Joseph Perrir		1746				
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHC THE M - Extens after S - If the p - If NO - Failure - Any re	PRTENED STATUTORY PERIOD FOR REF AILING DATE OF THIS COMMUNICATION ions of time may be available under the provisions of 37 CFR IX (6) MONTHS from the mailing date of this communication. eriod for reply specified above is less than thirty (30) days, a re- period for reply is specified above, the maximum statutory perion to reply within the set or extended period for reply will, by star- ply received by the Office later than three months after the ma- patent term adjustment. See 37 CFR 1.704(b).	N. 1.136(a). In no event, he reply within the statutory fod will apply and will expitute, cause the application.	owever, may a reply be tir minimum of thirty (30) day ire SIX (6) MONTHS from on to become ABANDONE	nely filed  s will be considered timely. I the mailing date of this communication. D (35 U.S.C. § 133).				
1) <b></b>	Responsive to communication(s) filed on 2	9 August 2001						
اصرا (2a	•	This action is nor	n-final					
3)□	Since this application is in condition for allo			rosecution as to the merits is				
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. <b>Disposition of Claims</b>								
4)⊠ Claim(s) <u>1-14</u> is/are pending in the application.								
4a) Of the above claim(s) <u>4-14</u> is/are withdrawn from consideration.								
5) 🗌 (	Claim(s) is/are allowed.							
6)🛛	6)⊠ Claim(s) <u>1-3</u> is/are rejected.							
7) 🗌 (	Claim(s) is/are objected to.							
8) 🗌 (	Claim(s) are subject to restriction and	d/or election requ	irement.					
Application	·							
•	he specification is objected to by the Exam							
10)⊠ T	he drawing(s) filed on 29 August 2001 is/ar							
	Applicant may not request that any objection to							
11)∐ T	he proposed drawing correction filed on			oved by the Examiner.				
If approved, corrected drawings are required in reply to this Office action.								
12) The oath or declaration is objected to by the Examiner.								
-	nder 35 U.S.C. §§ 119 and 120		051100 8440/	-) (d) -= (D				
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).								
•	All b) Some * c) None of:	anta baya basa s	and and					
	1. Certified copies of the priority documents have been received.							
	2. Certified copies of the priority documents have been received in Application No							
<ul> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>								
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).								
a)	☐ The translation of the foreign language cknowledgment is made of a claim for dom	provisional applic	ation has been re	ceived.				
Attachment	-	oodo priority and	33 12	<del></del>				
1) Notice	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s	5)		ry (PTO-413) Paper No(s) Patent Application (PTO-152)				

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### **DETAILED ACTION**

#### Election/Restrictions

- 1. Restriction to one of the following inventions is required under 35 U.S.C. 121:
  - I. Claims 1-3, drawn to a method of cleaning a substrate, classified in class34, subclass 443+.
  - II. Claims 4-14, drawn to a substrate cleaning apparatus, classified in class134, subclass 153.
- 2. The inventions are distinct, each from the other because of the following reasons:
- 3. Inventions I and II are related as process and apparatus for its practice. The inventions are distinct if it can be shown that either: (1) the process as claimed can be practiced by another materially different apparatus or by hand, or (2) the apparatus as claimed can be used to practice another and materially different process. (MPEP § 806.05(e)). In this case the process as claimed can be practiced by another materially different apparatus such as an apparatus without a chemical fluid supply means or multiple inert gas supply ports.
- 4. Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, and the search required for Group II is not required for Group I, restriction for examination purposes as indicated is proper.
- 5. During a telephone conversation with Applicant's representative, Mr. Stephen Adrian, on 01 November 2002 a provisional election was made without traverse to

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prosecute the invention of Group I, claims 1-3. Affirmation of this election must be made by applicant in replying to this Office action. Claims 4-14 are withdrawn from further consideration by the examiner, 37 CFR 1.142(b), as being drawn to a non-elected invention.

6. Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a request under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(i).

## Claim Rejections - 35 USC § 112

- 7. The following is a quotation of the second paragraph of 35 U.S.C. 112:

  The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 8. Claims 1-3 are rejected under 35 U.S.C. 112, second paragraph, as being incomplete for omitting essential steps, such omission amounting to a gap between the steps. See MPEP § 2172.01. The omitted steps are: applying a wet-cleaning treatment to the wafer. The claims, which are directed to a method of wet-cleaning wafers, omit any wet-cleaning steps.

# Claim Rejections - 35 USC § 102

9. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

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A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

10. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by US 5,377,708 to Bergman et al.

Bergman et al. discloses the claimed invention of a wafer wet-cleaning method by applying a spin dry process to a wafer by supporting and rotating the wafer and supplying an inert gas, such as nitrogen, at the outer peripheral portion of the wafer, such that the sealed drying space is formed at the outer peripheral portion of the wafer and an inert gas atmosphere is achieved (see entire reference of Bergman et al., for instance, Figure 1, col. 8, lines 19-22).

11. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by US 4.544.446 to Cady.

Cady discloses the claimed invention of a method of wet-cleaning wafers by spin drying a wafer while flowing inert gas, such as nitrogen, to the face of the wafer (see entire reference of Cady, for instance, Figures 1-2, col. 3, lines 38-49, and col. 4, lines 48-56). Cady also discloses the sealed drying space 40 is sealed for "removing any entrained and undesirable gases or contaminants", and supplying inert gas such that the gas supply at the outer peripheral portion is larger than that of the center portion (see entire reference, for instance, col. 7, lines 44-58, and Figures 6-8B, respectively).

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#### Conclusion

12. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

US 6,270,584 to Ferrel et al., which discloses a method for wet-cleaning wafers by supplying inert gas to a wafer surface.

- 13. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Joseph Perrin, Ph.D. whose telephone number is (703)305-0626. The examiner can normally be reached on M-F 7:30-5:00, except alternate Fridays.
- 14. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Randy Gulakowski can be reached on (703)308-4333. The fax phone numbers for the organization where this application or proceeding is assigned are (703)872-9310 for regular communications and (703)872-9311 for After Final communications.
- 15. Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703)308-0661.

Joseph Perrin, Ph.D.

Examiner Art Unit 1746

JIP November 5, 2002

> PANDY GULAKOWSKI SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 1700